

Press Release

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The Cornell NanoScale Science & Technology Facility (CNF) purchases Nanonex Advanced Nanoimprint Tool

Princeton NJ, Jul. 30, 2008: Nanonex Corporation, the inventor and world's leading provider in nanoimprint lithography solutions with the longest history, announces the purchase of a Nanonex NX-2500 by the Cornell NanoScale Science & Technology Facility (CNF) at Cornell University in Ithaca NY.

Nanonex Corp, the inventor and innovator of nanoimprint lithography solutions, announces the purchase of a Nanonex NX-2500 by Cornell University, CNF, Ithaca, NY. The purchase of this imprint tool was made possible by a grant from KAUST. "Nanoimprint has entered into the mainstream and Nanonex technology provides the most versatile system for the diverse user community at CNF" Don Tennant, CNF Director of Operations.

"We at Nanonex are very excited about the selection by CNF, the national nanofabrication facility with the longest history and the largest user base, as the preferred vendor for nanoimprint solutions. We look forward to our partnership in supporting research at the CNF facility." Said Larry Koecher, the Chief Operating Officer of Nanonex.

The Nanonex NX-2500 is a full-wafer nanoimprinter capable of all forms of imprint: thermal, photo-curable, embossing and their combinations, with sub-5 nm resolution and accurate alignment. Based on Nanonex's unique patented Air Cushion Press™ and other technologies, the NX-2500 offers unsurpassed nanoimprint uniformity, flexibility in handling different sizes and types of wafers and masks, high yield and easy operation.

About Nanonex Corporation

Nanonex is the inventor of "nanoimprint lithography", the world's first nanoimprint lithography company, and the world's leading provider of nanoimprint solutions that include equipment, masks, resists and processes. Nanonex's patented and proprietary nanoimprint lithography (NIL) solutions and Air-Cushion Press™ can manufacture 3D nanostructures with sub-5 nm resolution, large-area uniformity, accurate overlay alignment, high throughput, and low cost. Nanonex NIL solutions have been adopted by a broad spectrum of industry applications, such as optical devices, data storage,

displays, light emitting diodes, semiconductor ICs, biotech, chemical synthesis, and advanced materials. Nanonex has over 100 customers and an installed base of more than 40 tools world-wide. Visit www.nanonex.com for additional information.

The Cornell NanoScale Science & Technology Facility (CNF)

CNF is a national user facility that supports a broad range of nanoscale science and technology projects by providing state-of-the-art resources coupled with expert staff support. 2007 marks our 30th year in operation (30th Anniversary Celebration).

Research at CNF encompasses physical sciences, engineering, and life sciences, and has a strong inter-disciplinary emphasis. Over 700 users per year (50% of whom come from outside Cornell) use the fabrication, synthesis, computation, characterization, and integration resources of CNF to build structures, devices, and systems from atomic to complex length-scales.